Erratum to: Spectral and Morphological Studies of Nanocrystalline Silicon Thin Films Synthesized by PECVD for Solar Cells

P. M. Anbarasan · P. Senthilkumar · S. Manimegalai ·
M. Geetha · K. Vasudevan · V. Ravi · D. Deivasagayam ·
V. Aroulmoji

Published online: 20 July 2010
© Springer Science+Business Media B.V. 2010

Erratum to: Silicon (2010) 2:7–17
DOI 10.1007/s12633-009-9028-9

The original submitted version of this article unfortunately contained mistakes.

Dr. S. Moorthy Babu had been accidentally added as a co-author during the submission of the manuscript and his name should be removed as one of the co-authors.

Reference 36 of the article should be changed to read:

36. (a) Ram SK, Islam MN, Cabarrocas PR, Kumar S (2008) Thin Solid Films 516 (2008) 6863–6868: (b) Ram SK (2006) Ph.D thesis, I.I.T. Kanpur, India.

The online version of the original article can be found at <http://dx.doi.org/10.1007/s12633-009-9028-9>.

P. M. Anbarasan (✉) · P. Senthilkumar · S. Manimegalai ·
M. Geetha · K. Vasudevan · V. Ravi
Department of Physics, Periyar University,
Salem 636 011 Tamilnadu, India
e-mail: anbarasanpm@gmail.com

D. Deivasagayam
Nanorobotics Group, Department of Engineering Materials,
University of Sheffield,
36, Hurlfield, Avenue,
Sheffield S12 2TN, UK

V. Aroulmoji
PROTOS Research Institute,
Via Flavia 23/1, C/O Sviluppo Italia,
Trieste 34148, Italy